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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/625,769	07/23/2003	Brian G. Hoover	13621-43433	7825	
26257 7	7590 05/12/2006		EXAMINER		
RODEY, DICKASON, SLOAN, AKIN & ROBB, PA P.O. BOX 1888 ALBUQUERQUE, NM 87103			VARGOT, MATHIEU D		
			ART UNIT	PAPER NUMBER	
			1732		
			DATE MAILED: 05/12/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)			
Office Action Summary		10/625,769	HOOVER, BRIAN G.			
		Examiner	Art Unit			
		Mathieu D. Vargot	1732			
Period fo	The MAILING DATE of this communication app r Reply	ears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).						
Status	•					
1) 又	Responsive to communication(s) filed on <u>08 Ma</u>	arch 2006.				
•	<u></u>	· · · · · · · · · · · · · · · · · · ·				
·	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
,	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Dispositi	on of Claims	•				
4)⊠	Claim(s) <u>1-3,8-10,13,15-17 and 34-44</u> is/are pe	ending in the application.				
=	4a) Of the above claim(s) is/are withdrav					
5)	Claim(s) is/are allowed.					
6)⊠	Claim(s) 1-3,8-10,17,34-40,43 and 44 is/are re	jected.	•			
7)🖂	Claim(s) 13,15,16,41 and 42 is/are objected to.		·			
8)□	Claim(s) are subject to restriction and/or	r election requirement.				
Applicati	on Papers					
9)□	The specification is objected to by the Examine	r.				
10)	The drawing(s) filed on is/are: a) acce	epted or b) \square objected to by the ${ t E}$	Examiner.			
	Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).			
	Replacement drawing sheet(s) including the correcti	ion is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).			
11)	The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.			
Priority u	ınder 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
2) Notice 3) Information	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) r No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:				

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1.The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-3, 8-10, 17, 34-40, 43 and 44 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kumakura et al in view of Freeman et al.

Kumakura et al is applied generally for reasons of record, the primary reference failing to teach the provision of a mask through which the polymer film is irradiated to form surface relief thereon. Freeman et al clearly shows this and such would have been an obvious modification to the method of the primary reference to put diffractive geometry on the contact lens. It is submitted that the exact form of radiation used—ie, X-ray, ion bombardment, lithographic methods—would have been well within the skill level of the art as would using etching to form the surface relief structure. These methods are all well known in the art and one of ordinary skill would have had no problem determining which would be used most advantageously. In that Freeman teaches using a mask to make the surface relief structure, it is submitted that one of ordinary skill in this art would have found the use of a suitable mask to make the tracks/pores as obvious in the process of the primary reference. It is noted that masks are notoriously well known in the radiation/lithographic art to facilitate the formation of a desired pattern. Again, repeating the steps and using subsequent masks would have also been obvious.

2.Applicant's arguments with respect to the claims have been considered but are moot in view of the new ground(s) of rejection.

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In view of the amendment, Freeman et al has replaced Bawa et al as a secondary reference to teach the surface relief patterning of a polymeric film through a mask, the film serving in an optical manner as a corneal implant or adjunct. Applicant's arguments with respect to claims 13, 15, 16, 41 and 42 are persuasive and these claims have been objected to. It is respectfully submitted that the additional dependent claims set forth limitations which would have been obvious to one of ordinary skill in the art at the time of invention.

3.Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

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4. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Mathieu D. Vargot whose telephone number is 571 272-

1211. The examiner can normally be reached on Mon-Fri from 9 to 6.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Michael Colaianni, can be reached on 571 272-1196. The fax phone

number for the organization where this application or proceeding is assigned is 571-

273-8300.

Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

M. Vargot May 9, 2006 Mathieu D. Vargot Primary Examiner

M. Vings

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5/9/06